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# Studies on interstitial carbon doping from a Ti precursor in a hierarchical TiO<sub>2</sub> nanostructured photoanode by a single step hydrothermal route†

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Carbon doping from a Ti precursor in TiO<sub>2</sub> synthesized by a hydrothermal method was studied. The structural, optical and morphological study of the deposited material was carried out using X-ray diffraction, UV-vis spectroscopy and scanning electron microscopy characterization techniques. The elemental composition of the TiO<sub>2</sub> deposited with different precursor concentrations was studied using X-ray photoelectron spectroscopy and electron dispersive X-ray spectroscopy. The amount of elemental carbon in the TiO<sub>2</sub> matrix is found to be increased as the Ti precursor concentration is increased, which strengthens the proposed idea of carbon doping via a Ti precursor.

## 1. Introduction

A photoelectrochemical cell (PEC) is one of the best ways by which the abundant solar energy can be efficiently converted into electricity, and can be used to convert solar energy into any useful energy fuels by means of photocatalysis. A large number of materials which can be employed as a photoactive material in PECs have been investigated over the years, and out of these TiO<sub>2</sub> seems to be the most promising material due to its high efficiency, low cost, chemical inertness, eco-friendly nature and photostability.<sup>1–3</sup> However, the ability of this material is greatly limited by its low light harvesting in the visible region because of its wide band gap (for the rutile phase: 3.0 eV and for the anatase phase: 3.2 eV). Therefore, there has been much effort to enhance the visible light harvesting capacity of TiO<sub>2</sub>. One way is to sensitize the electrode surface with some sort of semi-conducting material which has a band gap in the visible region. This technique is not so popular when a photoelectrode is used for the water splitting application, because the sensitization causes burying of the active catalysis sites on the surface. The other way of enhancing the visible light harvesting capacity of the TiO<sub>2</sub> material is band gap tuning by introducing various types of impurities into the matrix of the material, *i.e.*, by

doping impurities into the TiO<sub>2</sub> matrix. This doping causes an effective decrease in the band gap energy of TiO<sub>2</sub> and this finally leads to increased visible light harvesting. There are numerous methods (such as metalorganic chemical vapour deposition (MOCVD), oblique-angle electron beam deposition, glancing angle deposition (GLAD) and so on) which have been reported for the synthesis of different TiO<sub>2</sub> nanostructures.<sup>4–7</sup> Among these methods, a hydrothermal method proved to be the best for the synthesis of TiO<sub>2</sub> nanostructures, because this method allows the production of the said material in an environmentally benign and simple way. This method also allows the easy alteration of the properties of materials such as crystallite size and morphology at a nanoscale by simply changing the synthesis parameters, such as reaction temperature, precursor concentration, pH and so on.

As discussed previously, the doping of the TiO<sub>2</sub> material allows the tuning of the band gap of TiO<sub>2</sub>, which makes it possible for this material to harvest the visible part of the solar spectrum. There are several reports where a red shift in the band gap energy of TiO<sub>2</sub> is reported. In most of the papers, pure TiO<sub>2</sub> was doped with different non-metal impurities such as N, S or C and so on.<sup>8–22</sup> In the present investigation there has been no intentional doping of any of the previously mentioned elements. However, one thing that has been deliberately investigated, is the possibility of incorporation of carbon from the starting material, *i.e.*, titanium(IV) isopropoxide (TTIP). The researchers particularly in the field of photocatalysis have thoroughly investigated the role of carbon in the TiO<sub>2</sub> matrix and the red shift observed in the band gap energy.<sup>8–18</sup> In order to explain the red shift observed in the system described in this paper, some of the most related experimental and theoretical works have been referred.<sup>9–11,17,18,23–35</sup> This paper particularly reports about the results obtained during the investigation of

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carbon doping from a Ti precursor. These results are the first of their kind because as far as is known up to now no one has reported such a focused study on doping of carbon from a Ti precursor. It is felt that this report will open a new avenue for researchers to tune the band gap of TiO<sub>2</sub> and will also pave the way for the creation of simultaneous doping and sensitization for an effective working photoanode for a variety of photoelectric applications.

So, the present manuscript reports on the possibility of carbon doping from a Ti precursor and the supporting characterization results; for example, X-ray diffraction (XRD) confirms the rutile phase of TiO<sub>2</sub>, X-ray photoelectron spectroscopy (XPS) confirms the presence of carbon in the TiO<sub>2</sub> lattice, electron dispersive X-ray spectroscopy (EDS) confirms the relationship of the precursor concentration to the carbon doping, and finally, optical studies confirm the actual band gap tuning of the material.

## 2. Experimental details

### 2.1. Thin film deposition

The TiO<sub>2</sub> was synthesised by the method reported previously by Burungale *et al.*, with some modifications.<sup>36</sup> The chemicals used were titanium(IV) isopropoxide (C<sub>12</sub>H<sub>28</sub>O<sub>4</sub>Ti) (99.98%, Alfa Aesar), and concentrated HCl (35.46%, Thomas Baker). Distilled water was used to prepare aqueous solutions. The F:SnO<sub>2</sub> (FTO) coated glass plates (~12 Ω cm<sup>-1</sup>, 1 cm × 3.5 cm) were used as substrates or supports for the TiO<sub>2</sub> films for the photoelectrochemical measurements.

In a typical experiment the hydrothermal inorganic precursor solution was prepared by mixing different amounts of TTIP (*i.e.*, 0.3 ml, 0.4 ml, 0.5 ml, 0.6 ml, 0.7 ml) in 10 ml of HCl and 10 ml of double distilled water. The samples were designated as T0.3, T0.4, T0.5, T0.6 and T0.7, respectively. The solution was then added into the Teflon lined stainless steel autoclave (with a capacity of 50 ml) containing FTO (conducting side facing up). Subsequently, the autoclave was maintained at 180 °C temperature for 3 h. The reaction time and reaction temperature were kept constant for all the experiments. The deposited thin films were annealed for 1 h at 450 °C.

### 2.2. Characterization of the TiO<sub>2</sub> thin films

A D2 PHASER XRD diffractometer (Bruker AXS GmbH, Germany) was used to record the XRD patterns of the samples and the X'Pert PRO MRD (Malvern PANalytical) PW3388/60 at the Energy Convergence Core Facility at Chonnam National University was used for further analysis. The elemental information of the TiO<sub>2</sub> thin film was obtained using XPS with a VG MultiLab 2000 (ThermoFisher Scientific, UK) with a microfocus monochromatic Al K<sub>α</sub> X-ray source at high photonic energies from 0.1 keV to 3 keV. The elemental maps and compositional analysis of the nanocrystals were obtained using an EDS system attached to a JSM-7500F FE-SEM (Jeol, Japan). The room temperature optical absorption measurements were performed in the wavelength range of 190–1100 nm using a UV-1800 UV-vis

spectrophotometer (Shimadzu, Japan). The surface morphology was examined using a JSM-6360 SEM (Jeol, Japan).

## 3. Results and discussion

### 3.1. X-ray diffraction

Fig. 1 shows the XRD patterns of all the TiO<sub>2</sub> samples. The XRD patterns matched well with those on the JCPDS card no. 01-076-0318 which confirmed the rutile phase with a tetragonal crystal structure. All the samples, except for the T0.4 sample, were polycrystalline in nature with a major peak corresponding to the (110) plane. The lattice parameters 'a' and 'c' were calculated using the formula:<sup>37</sup>

$$d_{hkl} = \frac{a}{\sqrt{h^2 + k^2 + l^2 \left(\frac{a^2}{c^2}\right)}} \quad (1)$$

The calculated values of the lattice parameters of all the samples were in good agreement with the standard lattice parameters of  $a = 4.508 \text{ \AA}$  and  $c = 3.027 \text{ \AA}$  which confirmed that the crystal system was tetragonal. By applying the Scherrer formula to the rutile (110) diffraction peaks, the average crystallite sizes of the samples were found to be 30, 35, 39, 36 and 30 nm for the samples T0.3, T0.4, T0.5, T0.6 and T0.7, respectively. Detailed XRD parameters are given in the Table 1.

### 3.2. X-ray photoelectron spectroscopy

In order to confirm the elements present in the deposited material and also to verify the probability of carbon doping

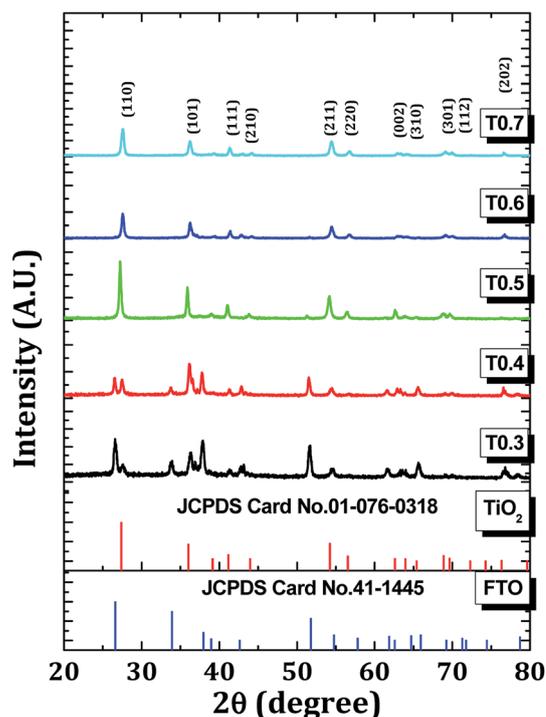


Fig. 1 The X-ray diffraction patterns of the T0.3, T0.4, T0.5, T0.6 and T0.7 samples.



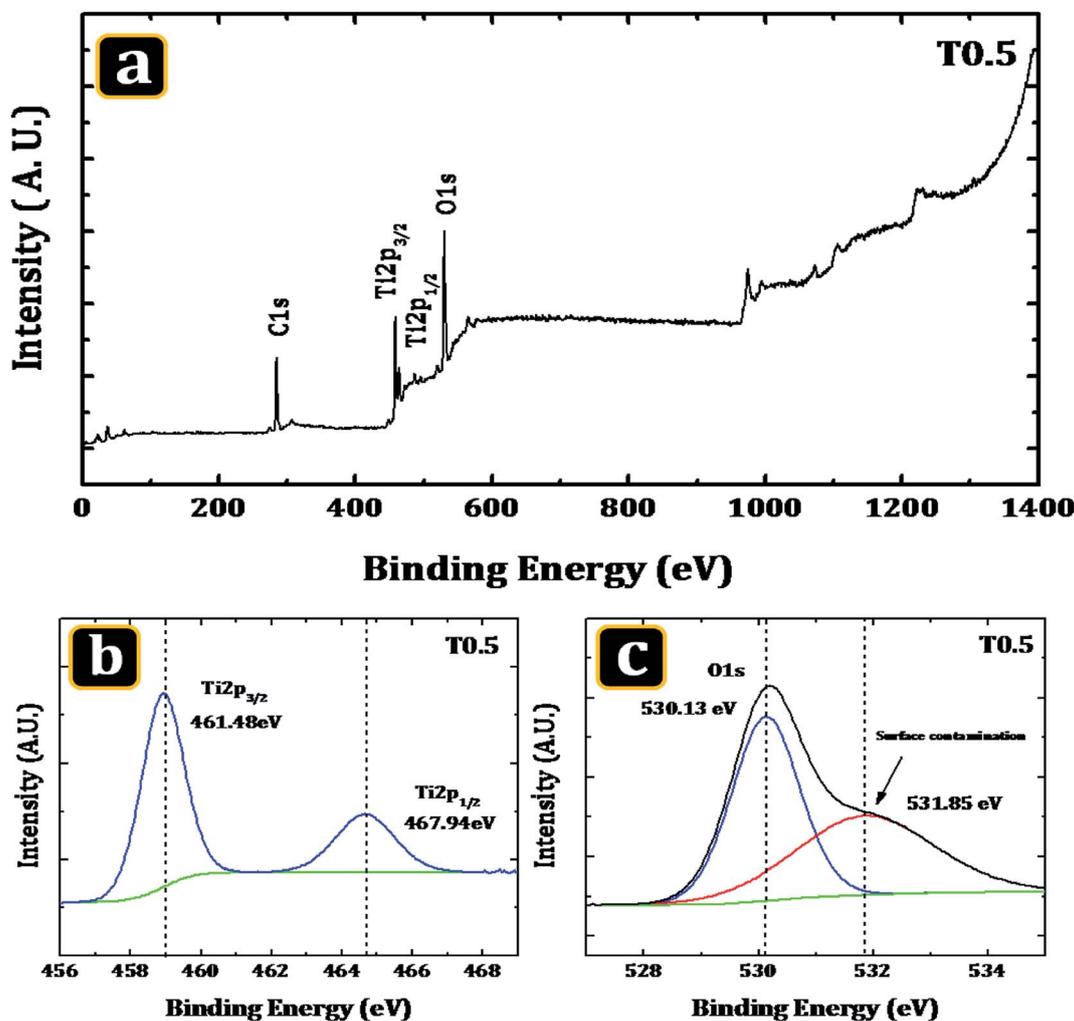
**Table 1** The detailed XRD parameters, for example, standard and calculated  $d$  values, standard and calculated values of the lattice parameters  $a$ ,  $c$  and the corresponding crystallite sizes of all the  $\text{TiO}_2$  samples are summarized in this table

Sample	$(hkl)$ plane	Standard $d$ (Å)	Calculated $d$ (Å)	Standard		Calculated		Crystallite size (nm)
				$a$ (Å)	$c$ (Å)	$a$ (Å)	$c$ (Å)	
T0.3	110	3.187	3.236	4.508	3.027	4.576	2.936	30
T0.4			3.243			4.586	2.952	35
T0.5			3.271			4.625	2.970	39
T0.6			3.232			4.570	2.946	36
T0.7			3.233			4.572	2.948	30

from the Ti precursor XPS was used. Fig. 2(a) shows the survey spectrum of the T0.5 sample and the high resolution XPS spectra of Ti (2p) and O (1s). The survey spectrum of the T0.5 sample revealed that the surface of the deposited material was composed mainly of Ti, O and a small amount of carbon. The presence of the carbon in the material may be due to two reasons: firstly it may be the adventitious carbon which

generally accumulates on the surface of a sample when it was being exposed to the ambient atmosphere; secondly this may be the carbon introduced into the matrix of the  $\text{TiO}_2$  from the Ti precursor during the hydrothermal synthesis.

Fig. 2(b) and (c) show a high-resolution scan of  $\text{TiO}_2$  in the Ti (2p) and O (1s) region. The two peak structure observed in the high-resolution spectrum of Ti (2p) suggest the presence of Ti in



**Fig. 2** The XPS spectra of the T0.5 sample. (a) A representative XPS survey of the sample showing the intense core-level lines of Ti, (b) the Ti (2p) core level spectrum and (c) curve fit of the O (1s) peak.



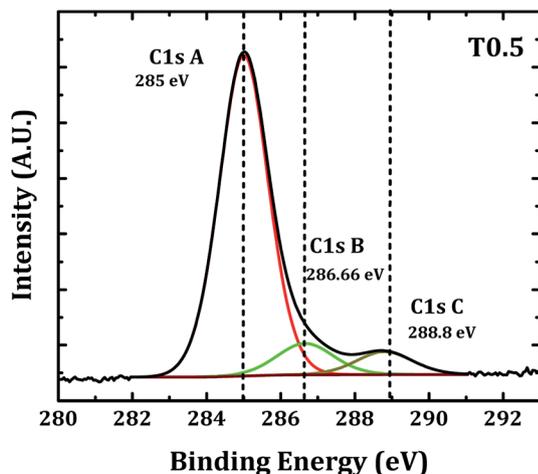


Fig. 3 Curve fitting of the C (1s) peak.

the material. The features of the double peaks of Ti ( $2p_{3/2}$ ) and Ti ( $2p_{1/2}$ ), were accurately determined by decomposing the Ti (2p) XPS spectrum of the T0.5 sample with a Voigt curve fitting

function inside the Shirley background. The decomposition of the Ti (2p) spectrum resulted in two peaks. These two decomposed peaks of the sample T0.5 were located at the binding energies of 461.48 eV and 467.94 eV. The peaks were related to the Ti ( $2p_{3/2}$ ) and Ti ( $2p_{1/2}$ ) core levels, respectively, of the  $Ti^{4+}$  cations of the  $TiO_2$  crystal structure. The considerable dislocation was not observed in the previous peak positions. These peak positions are similar to those reported by Pawar *et al.*<sup>38</sup> for  $TiO_2$  thin films. The energy separation between these two peaks was 6.46 eV, which was comparable to that observed in a  $TiO_2$  nanomaterial by Thind *et al.*<sup>39</sup> Similarly, Fig. 2(c) shows a compound double peak structure in the O (1s) spectrum of the T0.5 sample, suggesting the presence of the O element in the  $TiO_2$  rutile nanorods. A major O (1s) peak coupled with a small shoulder was observed. The two peaks, a strong peak having a centre at 530.13 eV and a little peak at 531.85 eV, resulted from the decomposition of the O (1s) spectrum. No considerable displacement of position was observed in case of peak. A strong peak observed in the spectra which was related to the  $O^{2-}$  anions is the characteristic peak of the  $TiO_2$ . The modest peak observed at the neighbourhood of the intense oxygen [O (1s)]

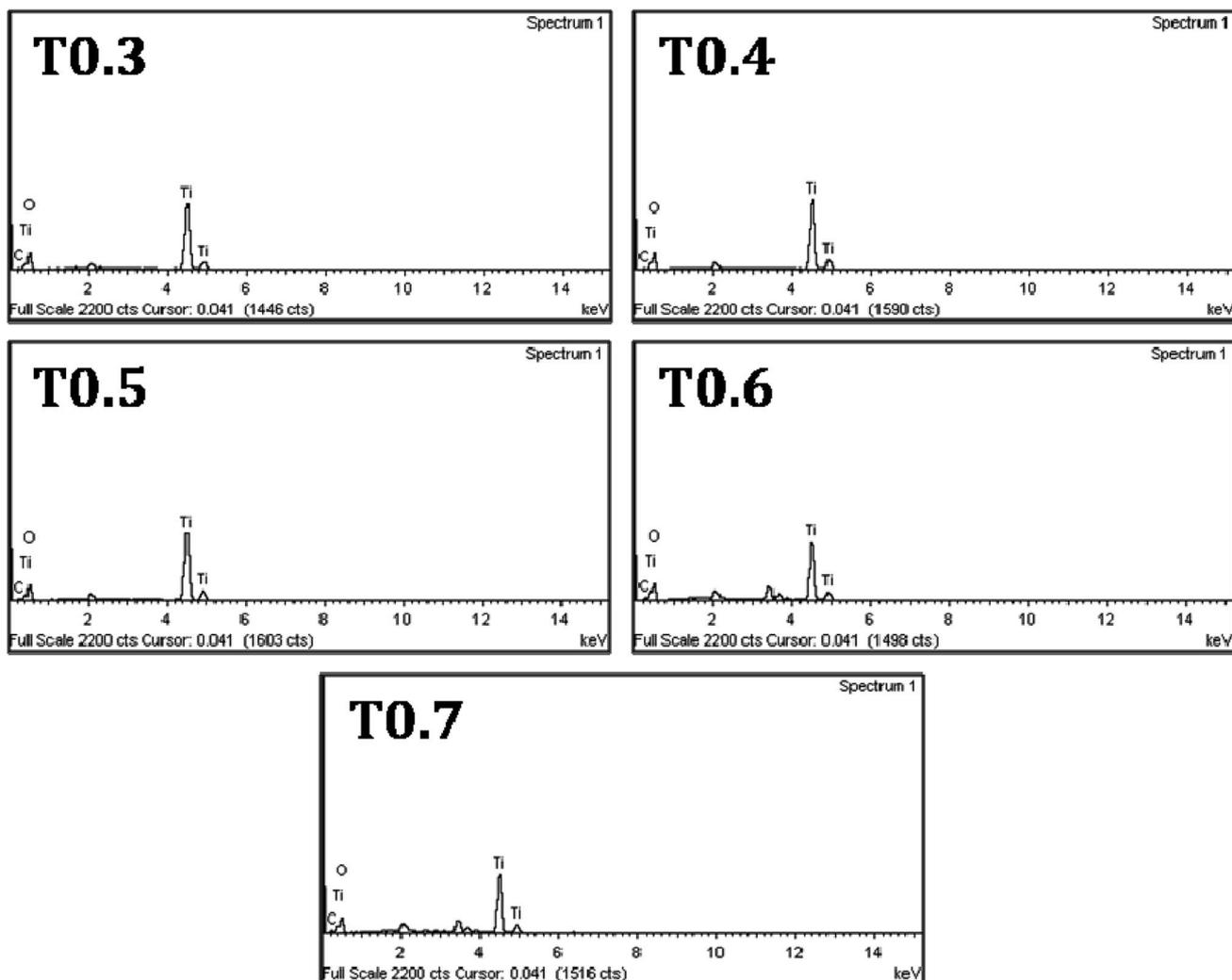


Fig. 4 The EDS spectra of the T0.3, T0.4, T0.5, T0.6 and T0.7 samples.



Table 2 Details of atomic mass and weight% of Ti, O and C elements in all the TiO<sub>2</sub> samples

Sample	Elements						Totals
	C K		O K		Ti K		
	Weight%	Atomic mass%	Weight%	Atomic mass%	Weight%	Atomic mass%	
T0.3	1.27	2.82	37.70	63.07	61.04	34.11	100.00
T0.4	1.60	3.68	34.24	59.24	64.16	37.08	100.00
T0.5	1.97	4.43	35.71	60.37	62.32	35.19	100.00
T0.6	2.73	5.93	37.73	61.60	59.54	32.47	100.00
T0.7	3.21	7.10	35.50	58.92	61.29	33.98	100.00

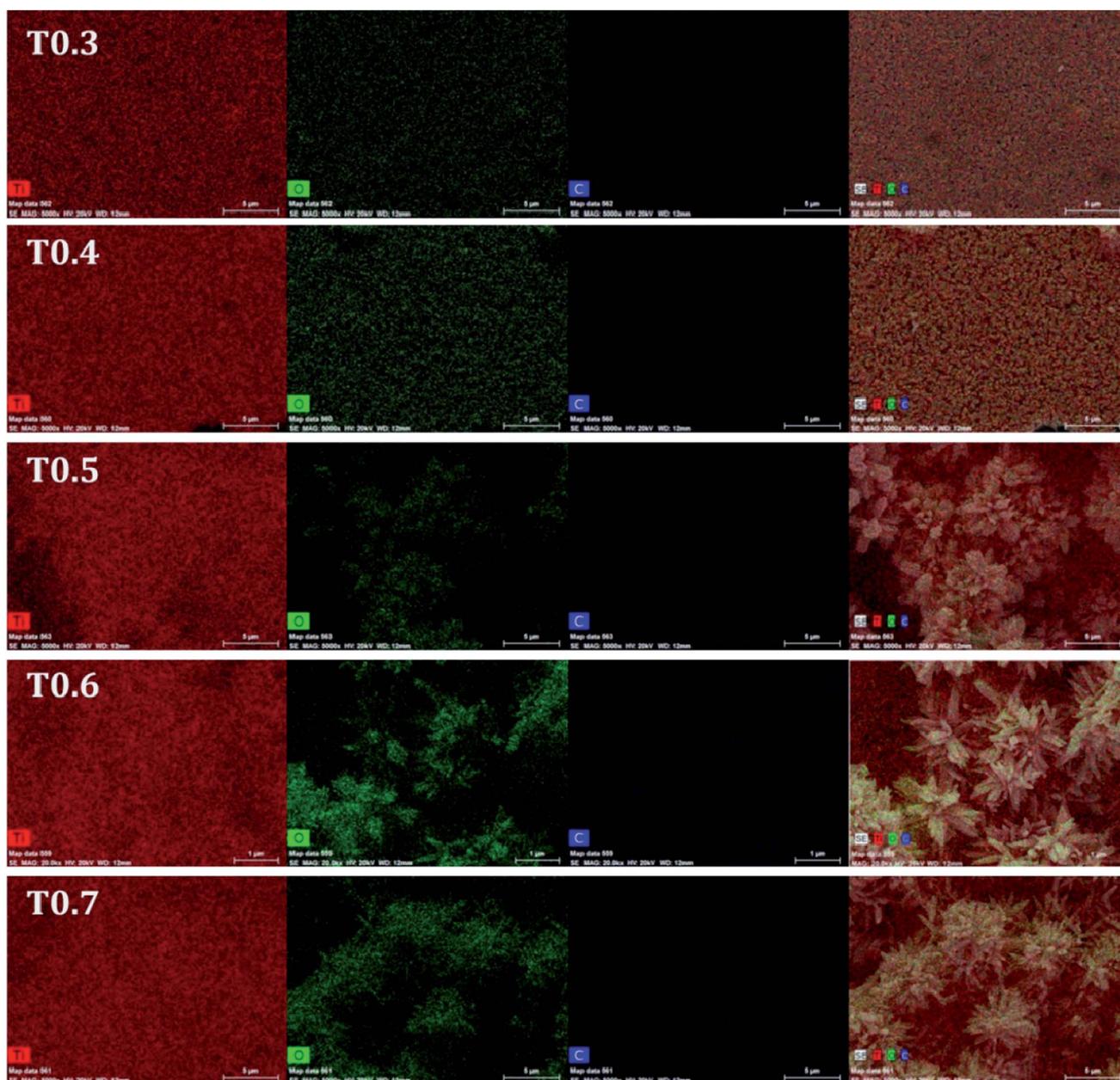


Fig. 5 The elemental mapping images of the T0.3, T0.4, T0.5, T0.6 and T0.7 samples for Ti, O and C elements.



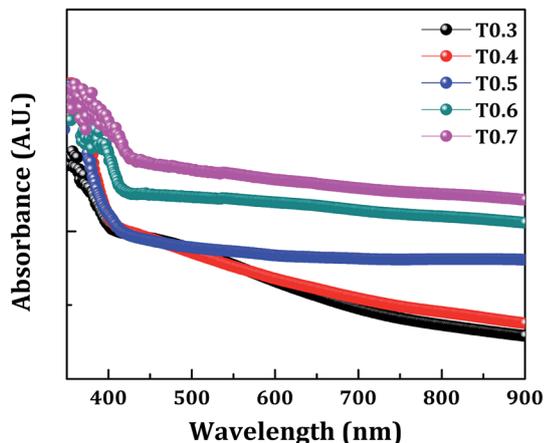


Fig. 6 The room temperature UV-visible absorption spectra of the samples T0.3, T0.4, T0.5, T0.6 and T0.7.

peak indicated surface contamination<sup>40–42</sup> or the occurrence of O containing species, such as hydroxyl groups or molecules of water that were adsorbed on the surface of the sample.<sup>43</sup>

Next the possibility of carbon doping will be considered. According to the theoretical work done by Valentin *et al.*<sup>18</sup> on anatase and rutile TiO<sub>2</sub>, there were three possible ways to include C atoms into the TiO<sub>2</sub> lattice. The first one was to replace the lattice oxygen with a carbon and the second one was to replace a Ti atom with a C atom. Both of these mechanisms implied the rupture of the Ti–O bonds that must be replaced by the Ti–C or the C–O bonds. The third possibility assumes that there was a stabilized carbon in an interstitial position. As discussed also in the same work, the

replacement of lattice oxygen with carbon or the presence of interstitial carbon may result in a series of localized occupied states in the band gap, which could explain the absorption edge shift observed experimentally for thin and nanostructured rutile films. But the replacement of Ti atoms by carbon did not result in any impurity states in the band gap. So, the replacement of Ti atoms by carbon atoms did not contribute to the decrease in the band gap of rutile TiO<sub>2</sub>. The presence of carbon species at different possible positions could be observed experimentally by using XPS.

It is well documented that the peaks observed in the XPS survey spectrum of carbon doped TiO<sub>2</sub>, 458.4, 529.7 and 284.8 eV corresponded to Ti (2p<sub>3/2</sub>), O (1s), and C (1s) core levels, respectively.<sup>10,11,20,44,45</sup> Generally, two peak structures at the binding energies of 284.8 and 288.6 eV were observed for the carbon-doped TiO<sub>2</sub>. The peak at 284.8 eV was thought to indicate the presence of adventitious elemental carbon and the peak at 286.6 eV indicated the presence of C–O bonds. If carbon was substituted for some of the lattice oxygen atoms and form a Ti–C structure then it showed a signature peak in the survey spectrum near 281.9 eV.<sup>23–25,27–29</sup>

In the present case the narrow scan spectrum of carbon in the TiO<sub>2</sub> thin film (Fig. 3) shows three peaks at the binding energies 285, 286.6 and 288.8 eV. As discussed previously the peak at 285 eV may be due to the presence of adventitious elemental carbon and the peaks at 286.66 and 288.8 eV indicated the presence of C–O and C=O or Ti–O–C bonds.<sup>10,24,26,28,29,31,32,34,35</sup> The absence of a peak near 281.9 eV confirmed that the substitution of carbon at Ti or O sites did not take place in our sample but the presence of peaks near 286.6 and 288.8 eV confirmed that the carbon was present in the TiO<sub>2</sub>

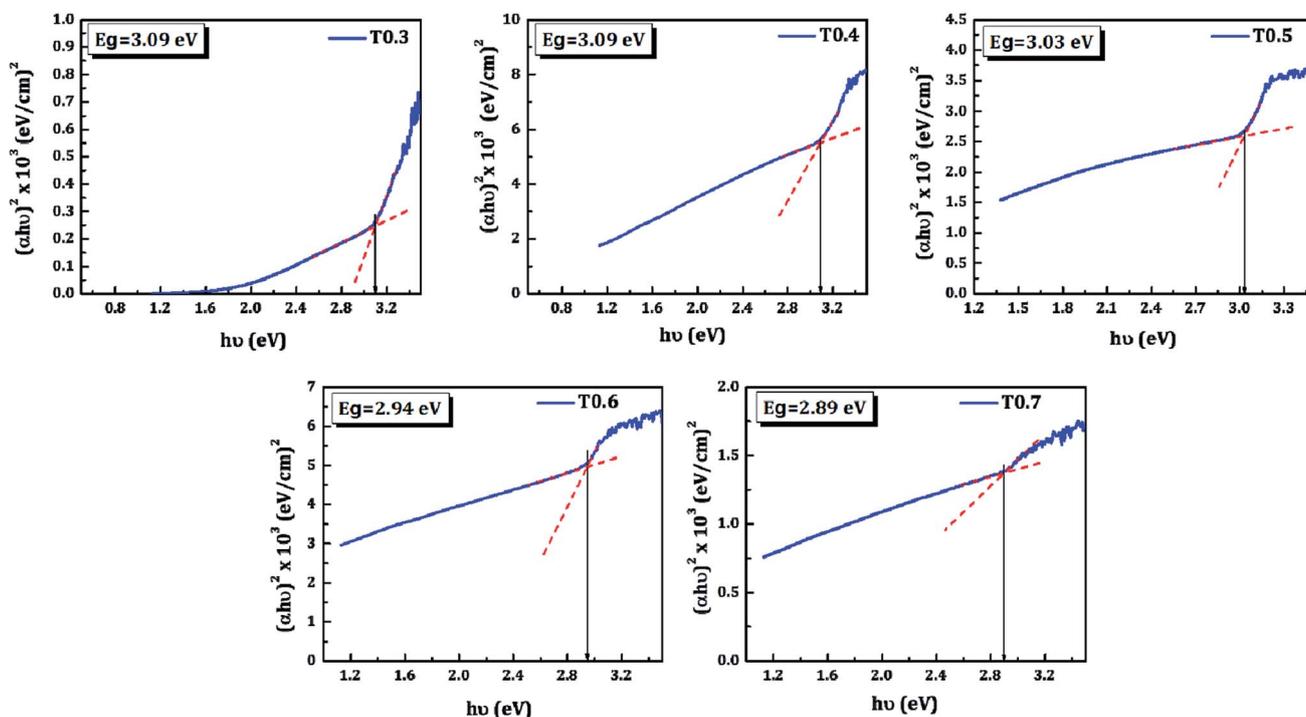


Fig. 7 The  $(\alpha h\nu)^{1/2}$  versus  $h\nu$  plots of the TiO<sub>2</sub> thin films.



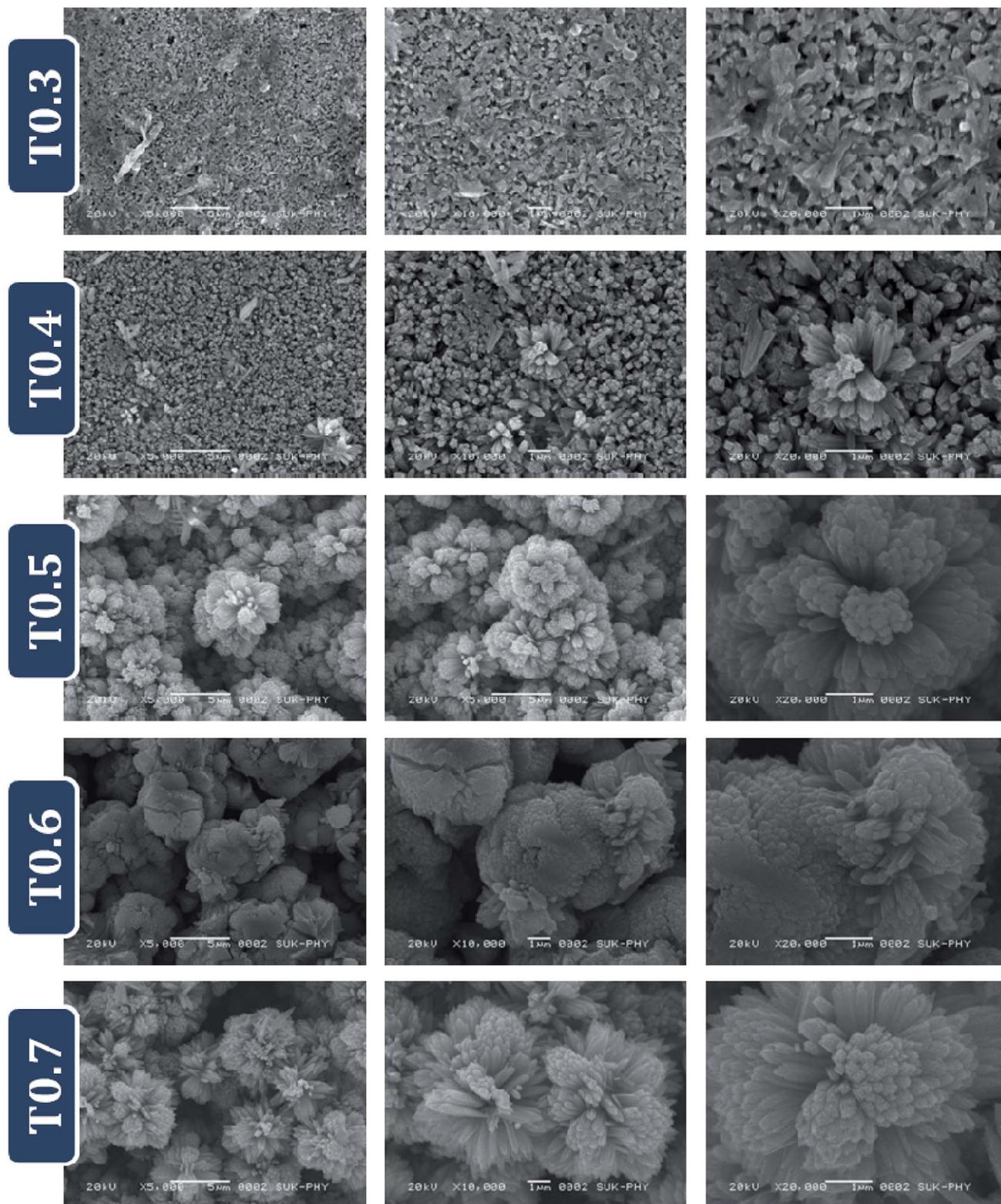


Fig. 8 The scanning electron microscopy images of the  $\text{TiO}_2$  samples at different magnifications.

lattice in the form of carbonated species which is also referred to as interstitial doping.<sup>31–33,35</sup> The decrease in the band gap of rutile  $\text{TiO}_2$  observed in the present investigation may be due to the interstitial carbon doping in the  $\text{TiO}_2$  lattice.

### 3.3. Electron dispersive X-ray spectroscopy

Further investigations regarding the presence of doped carbon in the matrix of  $\text{TiO}_2$  from Ti precursor, were carried out using



EDS and the spectra of all samples can be seen in Fig. 4. Details of the atomic mass and weight% of the Ti, O and C elements in each sample are given in Table 2. From the results it was observed that the weight percentage of C in the T0.3 to T0.7 samples was 1.27, 1.60, 1.97, 2.73 and 3.21, respectively, whereas the atomic mass percentage of C was 2.82, 3.68, 4.43, 5.93 and 7.10, respectively. These values of weight and atomic mass percentage of carbon in the T0.3 to T0.7 samples suggested that the percentage of carbon continued to increase as the Ti precursor concentration increased. So, by increasing the Ti precursor concentration, a greater amount of carbon may be introduced or doped into the TiO<sub>2</sub> matrix. In this way, the observed EDS results of elemental composition also strengthen the assumption that the carbon doping arises from the Ti precursor. The elemental mapping of all the TiO<sub>2</sub> samples for the elements Ti, O and C is also given in Fig. 5.

### 3.4. Optical absorption

The band gap energy ( $E_g$ ), the type of transition, and the absorption coefficient ( $\alpha$ ) of TiO<sub>2</sub> thin films was determined from the optical absorption spectra shown in Fig. 6, which lie mainly in the UV region due to its wide band gap. The absorption coefficient can be expressed by eqn (2):

$$\alpha hv = \alpha_0(hv - E_g)^n \quad (2)$$

where,  $\alpha$  is the absorption coefficient,  $hv$  is photon energy,  $E_g$  is band gap energy, and  $\alpha_0$  is a constant. The band gap energy was estimated by extrapolating the straight portion of  $(\alpha hv)^{1/2}$  versus photon energy ( $hv$ ), as shown in Fig. 7, and this indicates indirect and allowed optical transition. The values obtained for the band gap energy varied between 3.09–2.89 eV, thus a change was also observed in the band gap of TiO<sub>2</sub> upon variations of the Ti precursor concentration. As discussed in the XPS and EDS section this decrease in the band gap of the deposited TiO<sub>2</sub> material may be due to the presence of carbon in the matrix of the same material. In the present investigation the presence of carbon was observed in the XPS and EDS spectra, and the band gap energy was also decreased with variations in the Ti precursor concentration. So, the correlation of above three observations allows the assumption that there may be doping of the carbon from the starting material, *i.e.*, the Ti precursor and the doping increases with an increase in the Ti precursor concentration.

### 3.5. Scanning electron microscopy

The SEM images in Fig. 8 show the top view of the samples T0.3, T0.4, T0.5, T0.6 and T0.7 and Fig. S2 (ESI)<sup>†</sup> shows the cross-sectional images of respective samples. The growth mechanism related to the formation of TiO<sub>2</sub> nanorods and hierarchical microflower like structures has been discussed thoroughly in previous reports,<sup>36,46,47</sup> however it is also discussed briefly in the ESI<sup>†</sup> of this paper. The layer of compactly arranged TiO<sub>2</sub> nanorods is clearly observed in the SEM images of the T0.3 sample. The TiO<sub>2</sub> nanorods formed are about 1  $\mu$ m long and they form the subsequent compact layer after FTO on the glass substrates. From the SEM images of T0.4 it is also observed that there are some

homocentric but undeveloped TiO<sub>2</sub> microflowers. The average thickness of the T0.3 sample is about 1.15  $\mu$ m which due to the extra growth of the microflower like structures on the surface of T0.4, have an average thickness of about 2  $\mu$ m. In the third group of images, the T0.5 sample shows TiO<sub>2</sub> microflowers which have grown well, with 1–1.5  $\mu$ m long TiO<sub>2</sub> nanorods as the petals and this is clearly observed. The average diameter of the microflowers formed in the T0.5 sample is about 2–3  $\mu$ m. This new layer was formed over the first compact layer of the vertically aligned TiO<sub>2</sub> nanorods, which caused the increase in the film thickness, so the average film thickness of the T0.5 sample is about  $11 \pm 0.3$   $\mu$ m. When the precursor concentration was further increased there was formation of many layers of compact TiO<sub>2</sub> microflowers of diameter 2–3  $\mu$ m. Due to these microflowers the average thickness of the T0.6 samples increased up to 36  $\mu$ m. In cross sectional images the stacking of 5–6 layers of microflowers is clearly observed. The extra addition in the concentration level of Ti precursor just results in a thicker film of TiO<sub>2</sub>, which maintains the basic structure of compact microflowers with a diameter of 2–3  $\mu$ m. The average thickness of the T0.7 film was about 46  $\mu$ m.

## 4. Conclusions

In summary a TiO<sub>2</sub> photoelectrode was successfully prepared with hierarchical rutile TiO<sub>2</sub> nanostructures from a surfactant free, single step hydrothermal route. The effect of precursor concentration on the characteristics of the synthesized rutile TiO<sub>2</sub> was studied and the correlation of precursor concentration and corresponding optical properties is also discussed systematically. In brief, the observed decrease in the band gap energy of the samples allows the assumption that there is a possibility of interstitial carbon doping from the Ti precursor and it is also observed that this doping goes on increasing with the increase in the Ti precursor concentration.

## Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

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